



TNC Baseline Process Capability Development Plan

PLANNED 3DHI LOW-VOLUME/HIGH-MIX FOUNDRY TECHNOLOGIES	
1. Bonding	
Die-To-Wafer	Die-To-Wafer & Wafer-to-Wafer
Thermocompression	Hybrid
Cu-Cu Cu-Sn	Cu-Cu
2. Through Substrate Via (TSV) and Advanced Substrates	
Silicon	Glass
Compound Semiconductor	Polymer
Advanced Substrates	
3. Routing and Reconstitution	
Cu Routing Layers (200mm/300mm) Cu Damascene, RDL/Bump	
Sub-200mm Wafer Processing Enabled by Reconstitution	
Mixed-Material Reconstitution	
4. Thermal Solutions for Mixed-material 3DHI	
Engineered Thermal Materials & Systems	
Thermo-Mechanical Modeling & Reliability	
5. Failure Analysis, Characterization, Test & Reliability	
6. EDA and 3D Assembly Development Kit (3D-ADK)	

- Domestic State-of-the-Art 3DHI Foundry
 - Pure play 3DHI services
 - ITAR/EAR compliant operations
- Mixed-Materials Heterogeneous Integration (3DHI) Capability Built on a Silicon Advanced Packaging Baseline
 - Support for many wafer sizes and formats
 - All bonding completed at 200mm/300mm using reconstitution or related methods
 - Standardized planar interface with Cu Damascene processing to enable diverse materials integration
- 3D Assembly Design Kit and Support of EDA Vendors
 - Reference flows for prototype development
 - Digital Twin representation to support modeling
- Strategic Domestic Partnerships



NGMM Program Plan Summary

Phase 1
Establish Baseline Process

Phase 1 Deliverables
1.Initial Process Capability
2.Alpha ADK

Phase 2
Qualify / Operationalize

Phase 2 Deliverables
1. Qualified Process Capability
2. Beta ADK

End Goal
Ready for Customers

- Facility Preparation and Equipment Installation
 - Facility Refurbishment
 - Equipment Procurement and Installation
- Process Development
 - Initial Process Capability Development
- Electronic Design Automation
 - Workflows and Simulation
 - 3D-Assembly Design Kit (ADK)

- 3DHI Prototyping
 - Exemplar Microsystems and Design Challenge Prototypes to Exercise Process Capability
- Process Improvement
 - Automation of Fabrication, Assembly, and Test Processes
- Emulation/Digital Twin Capability Development

- 3DHI Capability
 - √ High Performance HI
 Microsystems
 - ✓ Research, Rapid Prototyping, and Manufacturing
 - **✓ Foundry Services**
 - **✓ITAR/EAR Compliant**
 - √Self-Sustaining
 - **✓** Cost Effective

Phase 1: 30 months

Phase 2: 30 months

3DHI Foundry Capability

Design Challenge Solicitation

Design Challenge

Distribution Statement A: Approved for public release; distribution unlimited

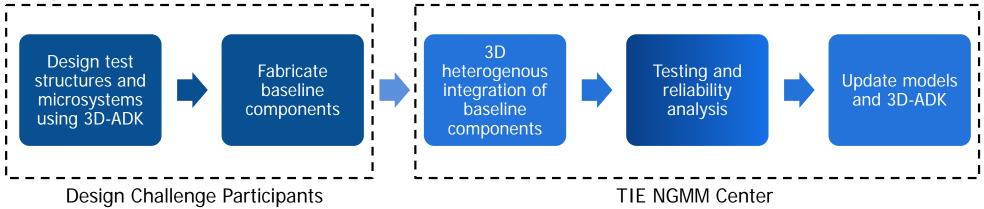


NGMM Design Challenge Program

Goal

- Opportunity for early engagement with TNC to demonstrate novel next generation prototypes showcasing the unprecedented performance of 3DHI technology
- Support long term sustainability and technical roadmap of the TIE NGMM Center
 - Exercise business, design, and fabrication processes aligned with TIE's existing capability

Program Structure



The NGMM Design Challenge will Drive Innovation and Bolster TNC Capability in 3DHI



NGMM 3DHI Microsystems RFI

3DHI RFI Response Topic Areas

RF Phased Array

Focal Plane Array

Power Converter

RF Components

Novel Sensors

Compute Architectures

NGMM Request For Information (RFI): 7/25-8/25

- Thank you for great response!
- Goal: Gain insight into community's innovative ideas to develop commercial and/or dual use 3DHI microsystems with TNC

Key Insights

- Significant interest in applications aligned with NGMM exemplars
- High interest in RF device implementations
- Interest aligned with NGMM 3DHI microsystem enablement
 - Thermal management technologies and EDA/3D-ADK

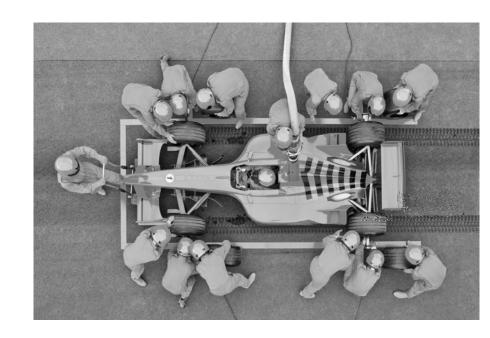
Additional Interest Areas

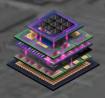
- Novel sensing
 - e.g, Architectures that incorporate MEMS or photonics
- Compute architectures



Have an idea? Interested in getting involved?

- Stay tuned for additional opportunities to engage with TIE and NGMM
- Connect with the DARPA team: send your ideas to ngmm@darpa.mil
- Monitor darpa.mil and sam.gov for current and future DARPA opportunities





Thank you for joining us for the 2025 NGMM Summit!

We hope that you had a chance to...

- Get an inside view of the program and opportunities to get involved
- Gain insight into the TNC Technology Roadmap and design/development infrastructure
- Learn about our progress around facility, infrastructure, equipment, and key milestones in process development

And leave with a perspective on...

- How the next generation of microelectronics performance will be enabled by 3DHI
- Our focus on developing the design enablement tools required for TNC customers and partners to be successful
- The importance of partnerships in the success of not just NGMM, but of the larger domestic microelectronics community